Docket No.

202450US0

IN RE APPLICATION OF: Atsushi SHIOTA, et al.

SERIAL NO: 09/770,289

FILED:

January 29, 2001

RCE FILED: October 9, 2003

FOR:

PROCESS FOR PRODUCING SILICA-BASED FILM, SILICA-BASED FILM, INSULATING FILM, AND

SEMICONDUCTOR DEVICE

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

Transmitted herewith is an Amendment in the above-identified application.

- No additional fee is required
- ☐ Small entity status of this application under 37 C.F.R. §1.9 and §1.27 is claimed.
- ☐ Additional documents filed herewith:

The Fee has been calculated as shown below:

CLAIMS	CLAIMS REMAINING		HIGHEST NUMBER PREVIOUSLY PAID	NO. EXTRA CLAIMS		RATE		CALCULATIONS
TOTAL	14	MINUS	20	0	х	\$18	=	\$0.00
INDEPENDENT	1	MINUS	3	0	х	\$86	=	\$0.00
☐ MULTIPLE DEPENDENT CLAIMS + \$290 = TOTAL OF ABOVE CALCULATIONS ☐ Reduction by 50% for filing by Small Entity					=	\$0.00		
					NS	\$0.00		
						\$0.00		
		☐ Recordation of Assignment + \$40 =				=	\$0.00	
		TOTAL					\$0.00	

	Α	check	in	the	amount	of	\$0.00	is	attached	Ĺ
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- ☐ Credit card payment form is attached to cover the fees in the amount of \$0.00
- Please charge any additional Fees for the papers being filed herewith and for which no check or credit card payment is enclosed herewith, or credit any overpayment to deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.
- If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. §1.136, and any additional fees required under 37 C.F.R. §1.136 for any necessary extension of time may be charged to Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

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ES PATENT & TRADEMARK OFFICE IN THE UNITED ST

IN RE APPLICATION OF

ATSUSHI SHIOTA, ET AL.

: EXAMINER: FEELY, M.

SERIAL NO: 09/770,289

FILED: JANUARY 29, 2001

: GROUP ART UNIT: 1712

FOR: PROCESS FOR PRODUCING SILICA-BASED FILM, SILICA-BASED : RCE FILED: OCTOBER 9, 2003

FILM, INSULATING FILM, AND

SEMICONDUCTOR DEVICE

<u>AMENDMENT</u>

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated June 30, 2004, please amend the aboveidentified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.